Gold-Tin Solder Wetting Behavior for Package Lid Seals: *A Case Study*

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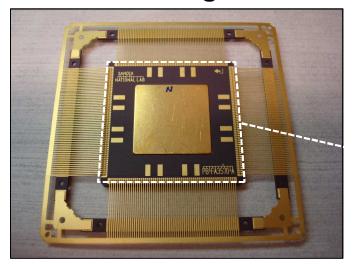
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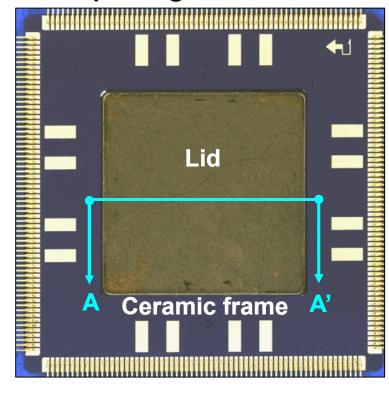


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◆ The 80Au-20Sn (wt.%) solder alloy it suitable for the hermetic sealing of ceramic electronic packages.



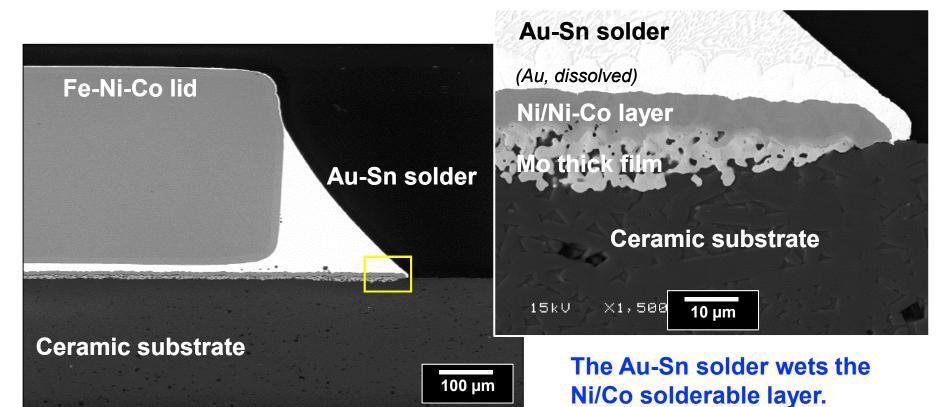


A - A'

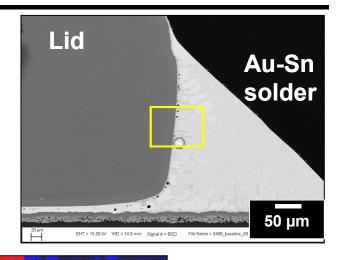


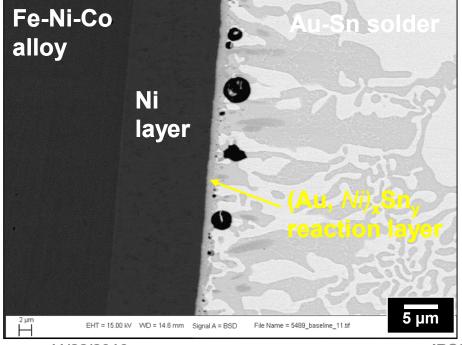
◆ A Mo thick film and electroplated Ni/Co and Au layers support Au-Sn wetting and spreading on the ceramic substrate (frame).

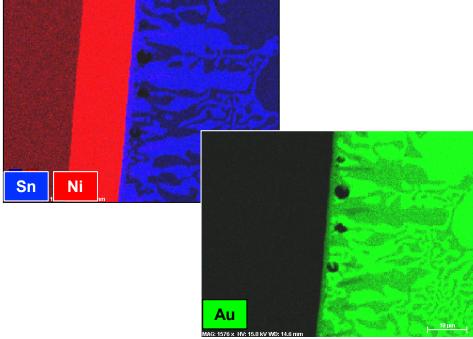


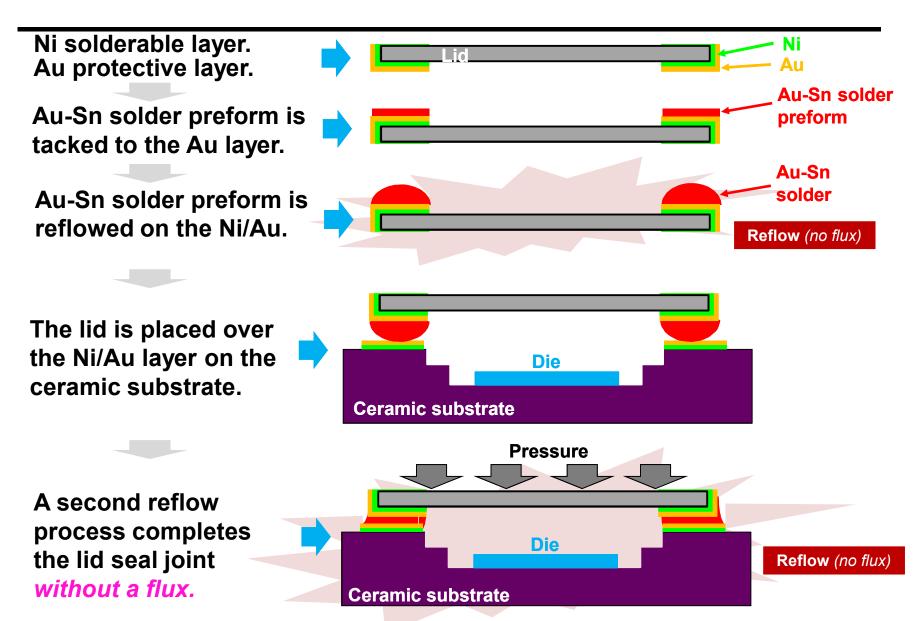


- The Au-Sn solder wets and spreads on the Ni solderable finish of the lid.
 - A Au protective finished dissolved into the molten Au-Sn solder.
- The reaction layer is (Au, Ni)_xSn_y intermetallic compound (IMC) having (unexpectedly) only a trace of Ni.



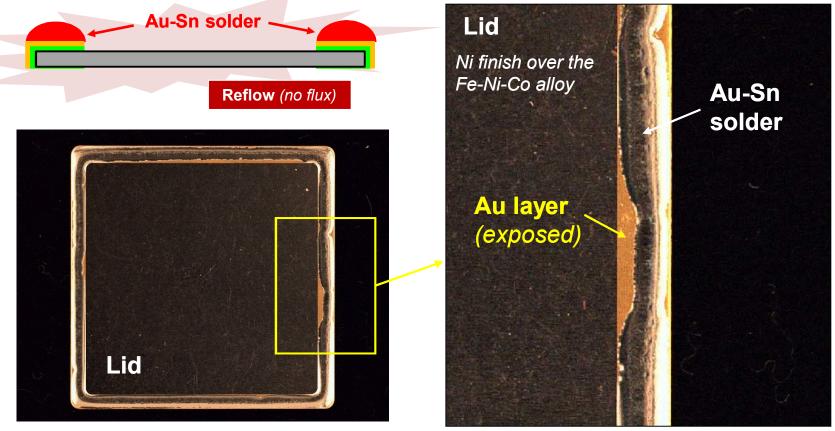






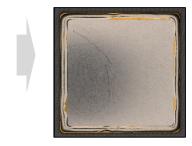
Problem

- The 80Au-20Sn solder preform was reflowed on the lid in preparation for the sealing of the electronic package.
- Areas of non-wetting appeared that were indicated by exposure of the Au-Ni finish around the lid perimeter.



Approach

- Question #1: Are non-wetted areas due to poor solderability or simply the wetting-and-spreading "dynamics" of Au-Sn solder?
- Question #2: If poor solderability, what is (are) the root-cause(s)?
 - Organic contamination on the Au surface?
 - Ni-O formation on the surface due to Ni diffusion?
- Methodology #1: Perform surface and depth profile analyses of the Au finish on existing lids using Auger Electron Spectroscopy (AES).



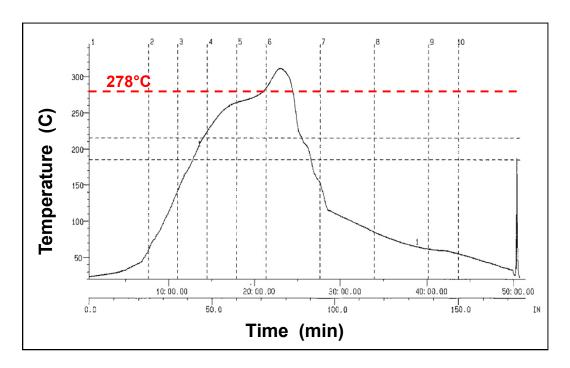
Methodology #2: Perform AES surface and depth profiles on pristine lids exposed to a thermal profile that simulates that used to reflow the Au-Sn solder.



The AES analyses were performed at multiple sites to confirm reproducibility.

Approach

Methodology #2 (con't): A simulated Au-Sn reflow thermal profile was developed in the Gleeble™ 3500 system:

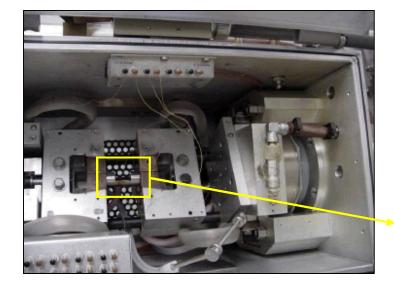


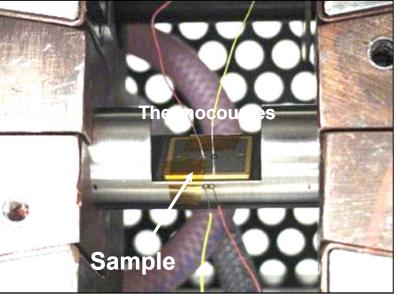
- The simulate reflow was performed in either nitrogen or air atmospheres to account for the two extreme conditions.
 - Organic contamination and Ni diffusion are both sensitive to the atmosphere above the Au surface.

Approach

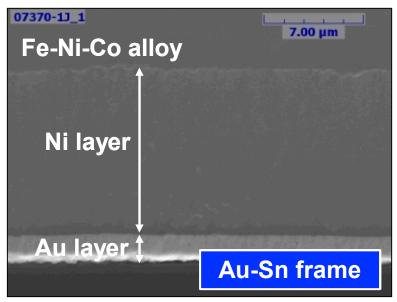
Methodology #2 (con't): These photographs show the equipment and set-up of the test specimen in the Gleeble™ apparatus.





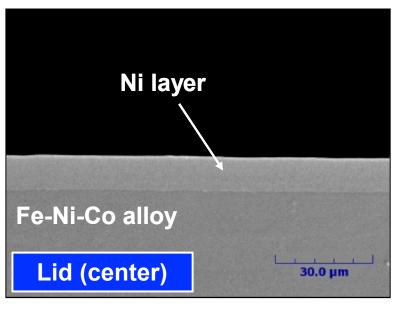


- The Ni and Au thicknesses were measured on the lid.
 - The Ni thickness was determined at the site of the Au-Sn solder bond as well as in the center of the lid.



Ni: 11.6 \pm 0.1 μ m.

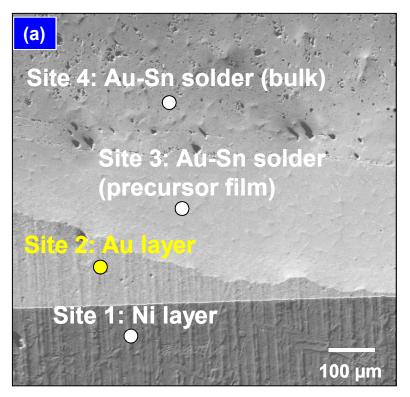
Au: $1.68 \pm 0.06 \, \mu m$.

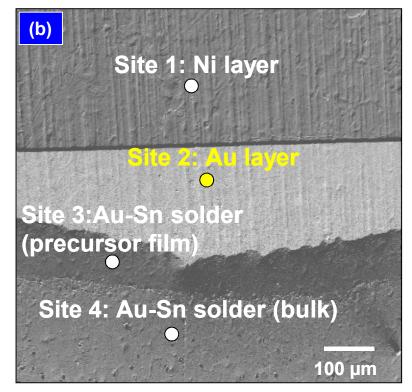


Ni: $10.3 \pm 0.4 \, \mu m$.

The Au and Ni layers were sufficiently thick to serve their respective functions as protective and solderable finishes.

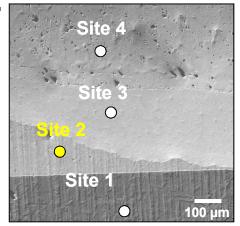
- Two locations were examined on an existing lid: (a) and (b).
- Four "sites" were analyzed per the two locations, each of which reflected a different structure.
 - Site 2 was of particular interest because it was the non-wetted Au layer surface.





The AES surface survey is shown for location (a).

- The C contamination of site 1, bare Ni surface, was "typical" and served as a suitable baseline.
- The C concentration is commensurate with the hydrocarbon "gettering" of Au surfaces.
- A trace of Ni on the Au surface represents minor Ni diffusion through the Au layer.

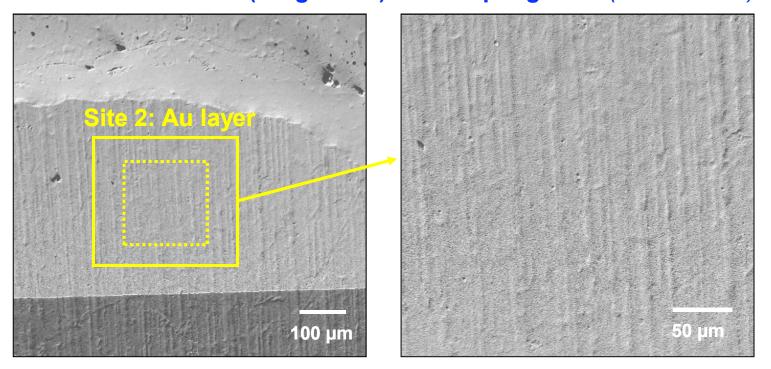


	Element Concentration (at.%)												
Site	С	N	0	P	S	CI	Са	Cu	Fe	Со	Ni	Au	Sn
1, Ni layer	35	2	18	1	1	0.5	1	0.1	1	1	37	2	0.5
2, Au layer	45	1	5	0.5	1	0.5	2	0.5	1	2	3	38	1
3, Au-Sn, precursor	50	1	18	0.5	0.5	0.1	1	0.5	1	1	0.5	15	11
4, Au-Sn, bulk	45	1	26	0.5	0.5	ND	1	0.1	1	2	0.5	7	15

Experimental error: $(\pm 1 - 2 \text{ at.}\%)$

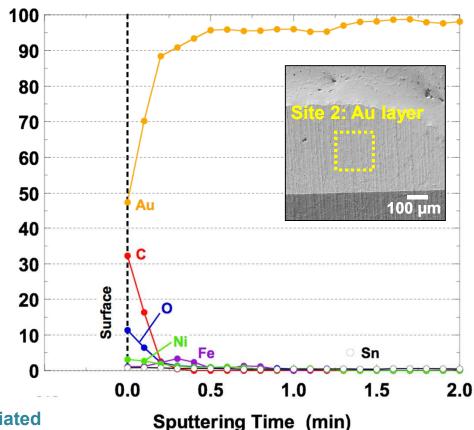
Ancillary organic contamination or undue Ni diffusion were not detected on the Au surface.

- An AES depth profile was performed at a site 2 surface (Au layer).
 - An initial surface survey was conducted within the solid box.
 - The depth profile was performed in the dashed box area.
 - Surface features (roughness) ≪ sampling area. (Preferred ...)



◆ The AES surface survey reproduced the previous data to within the experimental error (± 1 – 2 at.%) of the technique.

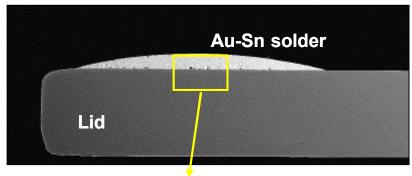
- The AES depth profile is shown for site 2 (Au layer).
- The C at.% level is typical; it quickly dropped off in the layer, which implies that its source is atmospheric and not contamination from the plating bath ("drag-out").
- The Ni at.% level persisted in the near-surface region of the Au layer.
 - The Ni diffused to the surface under the oxidation potential and accumulated there in the absence of a concentration gradient
 - A 3 at.% Ni concentration and its associated Ni-O formation is just below levels that degrade wetting and spreading activity.

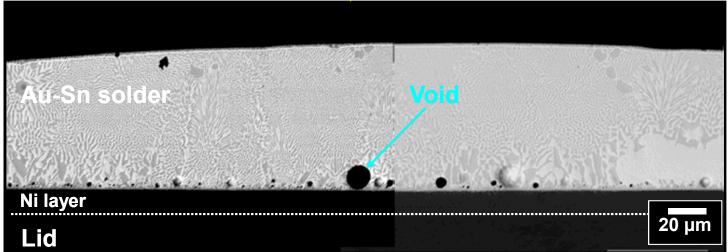


The Fe at. % level was most likely a plating bath contaminant.

Concentration (at.%)

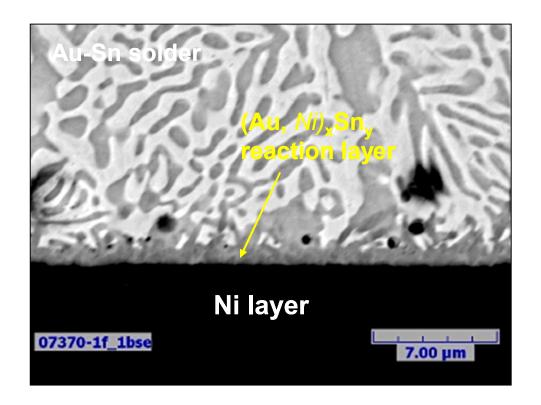
 Metallographic cross sections and scanning electron microscopy (SEM) were used to examine the Au-Sn solder on the lid.



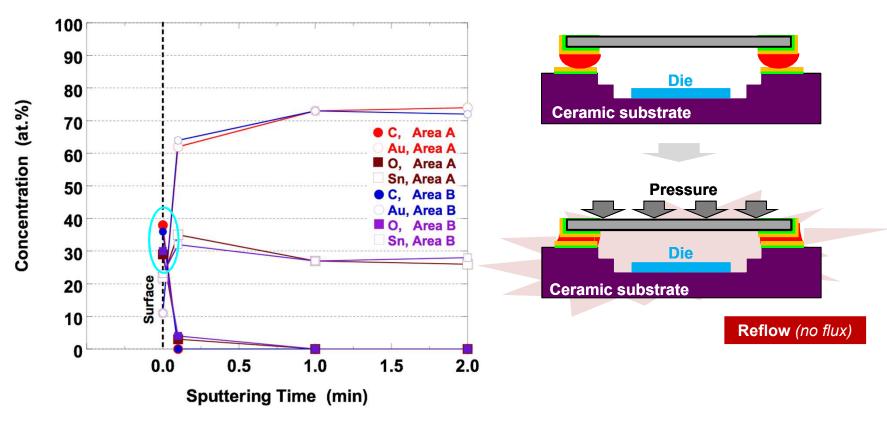


 "Champagne voids" are typically caused by the volatilization of organic compounds in the Au layer.

◆ The (Au, Ni)_xSn_y reaction layer indicated proper wetting of the Ni layer surface.



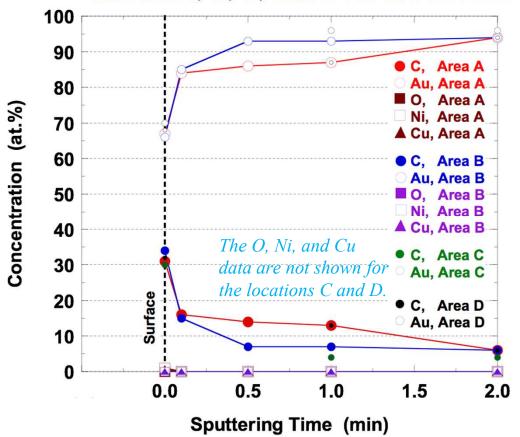
◆ The AES technique illustrated the C and O (oxide) species present on the surface of the Au-Sn preform (site 4).

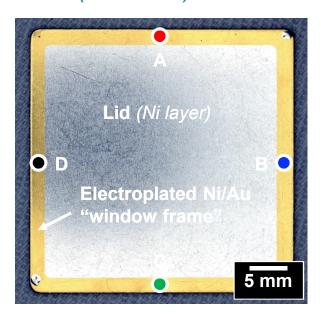


The mechanical pressure is required to break up the carbon/oxide skin on the preform to initiate wetting.

Results – Pristine Lid (without Au-Sn Solder)

- Two (2) pristine lids were obtained without the Au-Sn preform.
 - The AES analyses were performed at four (4) locations labeled A, B, C, and D for the baseline condition (no reflow).



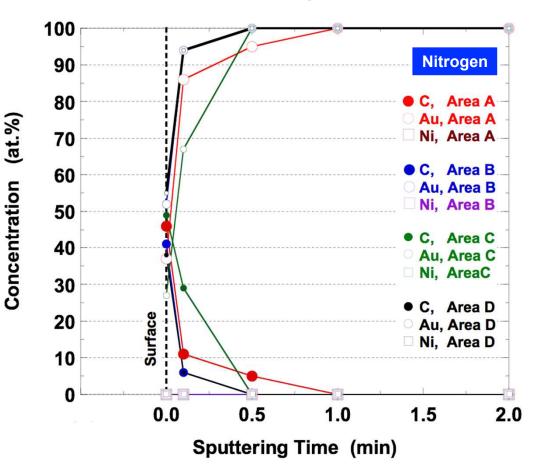


The C signal maintained a relatively high level of 5 – 15% through the Au thickness.

The C signal was caused by incorporated plating bath species.

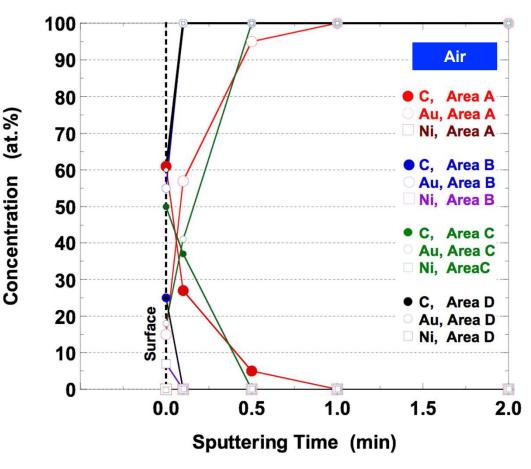
Results – Pristine Lid (without Au-Sn Solder)

- One (1) of each of the two (2) lids was exposed to the Au-Sn profile in nitrogen and the other, in air.
- The results of the Au-Sn profile performed in nitrogen are shown:
- The C at.% level was of a typical level at the surface.
- A loss of the C signal was observed with increasing depth into the Au layer.
 - The reflow process drives off the residual C entrapped in the Au layer from the plating step.
- The absence of a significant Ni signal indicates that the thermal profile (in nitrogen) did not drive Ni diffusion.



Results – Pristine Lid (without Au-Sn Solder)

- The results of the Au-Sn profile performed in air are shown:
- The surface and near-surface C signals were only slightly raised versus the nitrogen environment.
 - The small increase of C on the surface stemmed from hydrocarbons in the air or the exiting of C from the Au film.
 - A critical observation is that the air environment did not accelerate the diffusion of Ni in the Au.
 - Therefore, the relatively higher Ni contents of the lid already exposed to the Au-Sn reflow step, experienced an added exposure to high temperatures.



Summary

- ◆ The 80Au-20Sn (wt.%) solder forms the joint between a Fe-Ni-Co alloy lid and the ceramic frame to form the hermetic package.
- Non-wetting was frequently observed when the Au-Sn solder was initially reflowed to the lid Au/Ni frame (no flux).
- The likely scenarios were:
 - Organic contamination
 - Ni diffusion to the Au surface
 - Peculiarities of Au-Sn wetting behavior



Excessive organic contamination or Ni-O were not detected on the surface, implying that the non-wetting was caused by the intrinsic wetting-and-spreading ("peculiarities") of the molten Au-Sn alloy.

